

Docket No.: TESSERA 3.0-085 CONT DIV CIP DIV (PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Joseph Fjelstad

Application No.: 09/732,821

Filed: December 7, 2000

For: METHODS FOR MANUFACTURING

RESISTORS USING A SACRIFICIAL

LAYER

Commissioner for Patents Washington, DC 20231

10/10/01 V.Varnael Group Art Unit: 2812

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RESPONSE

Dear Sir:

The present communication is responsive to the restriction requirement mailed July 3, 2001.

In response to the restriction requirement, applicant hereby elects the claims of Group I, namely claims 1-42 for prosecution in the present application.

Dated: September 11, 2001

Respectfully submitted,

By_

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